FORM 1449*	INFO	RMATION DISCLOSU	RE STATEME	NT	Docket Number: 70020.0066USWO	Application N	10/543092		
		IN AN APPLICA	TION		Applicant: TAKASHI MIYAMATSU, ET AL.				
(Use several sheets if necessary)					Filing Date: JULY 22, 2005 Group Art Unit: UNASSIGNED			NED	
				U.S. PATENT DOC	CUMENTS				
EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILIN IF APPE	G DATE COPRIATI	
K.	AA	5,919,596	07/06/99	Hedrick, et al.	430	270/			
,	AB								
	AC								
	AD								
	AE								
	AF					L			
	AG								
	AH								
	AI			1					
	AJ								
	AK								
			FO	REIGN PATENT D	OCUMENTS				
		DOCUMENT NO.	DATE	COUNTR	Y CLASS	SUBCLASS	S TRANSLATION		
	_						YES	NO	
JE-	AL	EP 0 849 634 A1	06/24/98	Europe		_		x	
1	AM	JP 2002-229192	08/14/02	Japan		_		x	
Ł.	AN	GB1235815	06/16/71	Great Britain				x	
	AO								
		OTHER	DOCUMENT	S (Including Author	Title, Date, Pertinent Page	s, Etc.)			
	AP								
	AQ								
	AR								
	AS								

EXAMINER	CE	DATE CONSIDERED	6/2007							
EXAMINER: Initial ("ofference considered, whether or not chatton is in conformance with MPEP 809; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.										

## .... 1 3 2007

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

## NFORMATION DISCLOSURE STATEMENT (PTO 1449)

70020.0066USWO

10/543,092 CONFRMATION NC
10/543,092 4088

July 22, 2005

Takashi MIYAMATSU et al.

Unassigned 1752

SULFONIUM SALT COMPOUND, PHOTOACID GENERATOR, AND POSITIVE-TONE
RADIATION-SENSITIVE RESIN COMPOSITION

EXAMINER DOCUMENT NO. DATE NAME CLASS SUBCLASS FEMICIANT INTIAL

INTIAL

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

[JSC] C H. Bosshard, "S. Über die Anlagerung von Thiotethern an Chinone und Chinonimine in Stark sauren Medien," Helvetica Chimica Acta, Vol. 55, No. 1, pp. 32-37 (1972)

EXAMINER
/John Chu/
Date considered
06/21/2007

EXAMINER: Initial if the reference is considered, whether or not the classion is in conformance with MPEP 609. Draw a line through the citetio if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.